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Iodic Acid (HIO₃)

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This feature focuses on a reagent chosen by a postgraduate, highlighting the uses and preparation of the reagent in current research

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His research interests focus on the application of new reagents in organic reactions, the synthesis of organic compounds and some bicyclic fluorescent nucleosides.

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Introduction

Iodic acid (HIO₃) has attracted much interest owing to its potential as oxidant, ^{1–8} reagent ^{9–12} and acidic source. ^{13,14} The use of iodic acid has been known for a long time and has been widely employed in numerous and different organic reactions such as: oxidation of sulfides, ^{1,3} iodina-

tion, ^{10,12} deprotection, ¹³ nitrosation, ¹⁴ and dehydrogenation of aldehydes and ketones. ¹⁵ This reagent has several advantages: cost-effectiveness, non-toxicity, easy and clean workup of products.

Abstracts

(A) Patil et al. reported a useful method for the iodination of hydroxy aryl ketones; they showed a variety of *ortho*-hydroxy-substituted aromatic carbonyl compounds which were selectively iodinated in 81–87% yield by using iodine and iodic acid.¹⁰

$$\begin{array}{c} \text{OH} & \text{O} \\ \\ \text{I}_2 + \text{HIO}_3 \end{array}$$

(B) Zolfigol and co-workers have used HIO₃ and NaNO₂ in the presence of wet SiO₂ as a nitrosating agent for the effective and selective nitrosation of secondary amines under mild and heterogeneous conditions in good yields.¹⁴

$$\begin{array}{c} \begin{array}{c} \text{HIO}_3 \\ \text{NaNO}_2 \end{array} \\ \text{Wet SiO}_2 \\ \text{CH}_2\text{Cl}_2, \text{r.t.} \end{array} \begin{array}{c} \text{N} \\ \text{NO} \end{array}$$

(C) Shirini et al. reported a simple and efficient method for the oxidation of thiols to disulfides and sulfides to sulfoxides in 87–95% yield using aqueous HIO_3 at room temperature.³

Also Lakouraj and co-workers have explained the utility of HIO₃ for oxidation of sulfides to sulfoxides in the presence of wet SiO₂ under solvent-free conditions.¹

CI SH
$$\frac{\text{HIO}_3 \text{ (aq)}}{\text{r.t.}}$$
 CI S-S-CI

$$CH_2)_2S \xrightarrow{\text{HIO}_3 \text{ (aq)}} CH_2)_2S=O$$

$$R^1 \xrightarrow{\text{R}^2} \frac{\text{HIO}_3/\text{wet SiO}_2}{\text{solvent-free}} \xrightarrow{\text{R}^1} \frac{\text{R}^2}{\text{84-96\%}}$$

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(D) Ketoximes and aromatic aldoximes are converted to the corresponding carbonyl compounds with $\mathrm{HIO_3}$ under mild and heterogeneous conditions in $\mathrm{CH_2Cl_2}$ at room temperature in 67–97% yields.⁴

Also deoximation and dehydrazonation have been reported using HIO₃ in the presence of wet SiO₂ under solvent-free conditions. ¹⁶

(E) A variety of aldehydes and ketones were readily and selectively transformed to 1,3-saturated aldehydes and ketones with HIO $_3$ and I $_2$ O $_5$ at 45–65 °C in good yields. ¹⁵

(F) Hashemi and Akhbari showed the conversion of a variety of aromatic amines into their corresponding quinines under microwave irradiation.⁸

(G) A variety of thioacetals and thioketals were deprotected to the corresponding carbonyl compounds with HIO₃ in the presence of wet SiO₂ at room temperature under solvent-free conditions.¹³

$$\begin{array}{c|c}
S & HIO_3/\text{wet SiO}_2 \\
R_1 & S & \text{solvent-free}
\end{array}$$

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